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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.	
09/492,802 01/28/2000		Jong Hoon Yi	2658-0183P	1395	
	7590 02/14/2003 WART KOLASCH & I	EXAMINER			
PO BOX 747	RCH, VA 22040-0747	CHUNG, DAVID Y			
	,		ART UNIT	PAPER NUMBER	
1			2871	2871	
			DATE MAILED: 02/14/2003		

Please find below and/or attached an Office communication concerning this application or proceeding.

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			Application I	No.	Applicant(s)		
			09/492,802		YI ET AL.		
•	Offic Action Summ	ary	Examiner		Art Unit		
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Period fo	The MAILING DATE of this coor Reply	ommunication app	oears on the co	over sneet with the	correspondence add	iress	
THE - External from the control of t	IORTENED STATUTORY PER MAILING DATE OF THIS COI ensions of time may be available under the result of SIX (6) MONTHS from the mailing date of the period for reply specified above is less that of period for reply is specified above, the major to reply within the set or extended period reply received by the Office later than three led patent term adjustment. See 37 CFR 1.	MMUNICATION. provisions of 37 CFR 1.1 this communication. an thirty (30) days, a repl aximum statutory period d for reply will, by statute months after the mailing	36(a). In no event, by within the statutory will apply and will ex e, cause the applicat	however, may a reply be to minimum of thirty (30) da pire SIX (6) MONTHS fron ion to become ABANDON	imely filed ays will be considered timely in the mailing date of this co ED (35 U.S.C. § 133).	mmunication.	
1)	Responsive to communicati	on(s) filed on					
2a)□	This action is FINAL .		— nis action is no	n-final.			
3)□	Since this application is in c	ondition for allow	ance except fo	or formal matters, p	prosecution as to the	e merits is	
Disposit	closed in accordance with the closed in accordance with the closest cl	ne practice under	Ex parte Qua	yle, 1935 C.D. 11,	453 O.G. 213.		
4) 🛛	Claim(s) 1-26 is/are pending	in the application	n.				
	4a) Of the above claim(s)	is/are withdra	wn from consi	deration.			
5)	Claim(s) is/are allowe	d.					
6)🛛	Claim(s) 1-26 is/are rejected						
7)	Claim(s) is/are objected	ed to.					
. —	Claim(s) are subject to	o restriction and/o	or election requ	uirement.			
	tion Papers	. b. the Econolis					
	The specification is objected to	•		ta aka dika budho Ev	aminor		
10)	The drawing(s) filed on						
441	Applicant may not request that The proposed drawing correct					er	
ו ויי	If approved, corrected drawing				Toved by the Examin	J	
12)□	The oath or declaration is obje			o dollori.			
	under 35 U.S.C. §§ 119 and						
	Acknowledgment is made of		n priority unde	or 35 H.S.C. & 119	(a)-(d) or (f)		
	Acknowledgment is made of No All b) Some * c) No		in priority and	00 0.0.0. 3 1 10	(4) (4) 51 (1).		
a	1.⊠ Certified copies of the		ts have been r	eceived			
	2. ☐ Certified copies of the				ation No		
	3. Copies of the certified	•				Stage	
*	application from the See the attached detailed Offi	e International B	ureau (PCT Ri	ule 17.2(a)).		0.030	
14)	Acknowledgment is made of a	claim for domes	tic priority und	er 35 U.S.C. § 119	e(e) (to a provisiona	l application).	
	 a) The translation of the for Acknowledgment is made of a 						
Attachme	-		-				
2) 🔲 Not	ice of References Cited (PTO-892) ice of Draftsperson's Patent Drawing I		5		ary (PTO-413) Paper No al Patent Application (PT ·		



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DETAILED ACTION

Claim Rejections - 35 USC § 102

The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

(e) the invention was described in a patent granted on an application for patent by another filed in the United States before the invention thereof by the applicant for patent, or on an international application by another who has fulfilled the requirements of paragraphs (1), (2), and (4) of section 371(c) of this title before the invention thereof by the applicant for patent.

The changes made to 35 U.S.C. 102(e) by the American Inventors Protection Act of 1999 (AIPA) do not apply to the examination of this application as the application being examined was not (1) filed on or after November 29, 2000, or (2) voluntarily published under 35 U.S.C. 122(b). Therefore, this application is examined under 35 U.S.C. 102(e) prior to the amendment by the AIPA (pre-AIPA 35 U.S.C. 102(e)).

1. Claims 1-4, 6-16, 18-22, 25 and 26 rejected under 35 U.S.C. 102(e) as being anticipated by Kashiwazaki et al. (U.S. 5,922,401).

As to claim 1, 10, 13, 15 and 19 Kashiwazaki et al. discloses a TFT color liquid crystal display with the color filter formed on the TFT substrate. See figure 4. Note TFT 109, comprising: gate electrode 102, gate insulator 103, amorphous silicon layer 104, ohmic contact layer 106, source electrode 107 and drain electrode 108. Light-shielding

layer 111 is interpreted as being a barrier rib during the manufacturing of the color filter 113 shown in figures 5A-5K. Color filter 113 is formed via an ink-jet printing system.

As to claims 2, 11 and 22, Kashiwazaki et al. discloses forming light-shielding layer 111 by applying a black pigment containing resist. See example 13. This black resist is a low reflective layer.

As to claims 3 and 16, Kashiwazaki et al. discloses forming a contact hole in the light-shielding layer in order to connect pixel electrode 114 to drain electrode 108.

As to claims 4 and 12, the light-shielding layer of Kashiwazaki et al. prevents light leakage in addition to acting as a barrier rib during the manufacturing of the color filter.

As to claims 6 and 18, Kashiwazaki et al. discloses forming the pixel electrode 114 on color filter 113 as shown in figure 4.

As to claims 7, 8, 14, 20 and 21, Kashiwazaki et al. discloses that portions of the light-shielding layer corresponding to aperture areas 120 were removed by development. This would leave stripe-shaped portions overlapping the gate and data lines. The stripe-shaped portions overlapping the data lines define column areas that include the pixel cells in which the color filters are formed.

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As to claim 9, all liquid crystal displays inherently have a second substrate opposing the first substrate, with liquid crystal between the two substrates.

As to claims 25 and 26, each limitation recites forming a specific structural element shown in figure 4 of Kashiwazaki et al. The claims are therefore anticipated.

2. Claims 1, 2, 7-11, 13-15, 19-22, 25 and 26 rejected under 35 U.S.C. 102(e) as being anticipated by Izumi (U.S. 6,417,898).

As to claims 1, 10, 13, 15 and 19, Izumi discloses a liquid crystal display device with the color filter disposed on the active matrix substrate. See figure 1. Note scanning line 6, signal line 7, and pixel electrode 9. Note TFT 8, comprising: gate electrode 21, gate insulating film 22, semiconductor layer 23, source electrode 24 and drain electrode 25. Insulating layer 11 is interpreted as being a barrier rib during formation of the color filters as shown in figures 4(a)-4(d). Izumi discloses in column 6, lines 37 – 52 that various methods including ink jetting can be used to form the color filter.

As to claims 2, 11 and 22, Izumi discloses that the insulating layer 11 is produced by material such as SiN or acrylic resin. See column 5, lines 1-7. An acrylic resin insulating layer is a low reflective layer.



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As to claims 7, 8, 14, 20 and 21, figure 2 of Izumi shows that the insulating layer 11 has stripe-shaped portions arranged so as to overlap both the data lines and gate lines. Furthermore, these stripe-shaped portions define column areas that include the pixel cells in which the color filters are formed.

As to claim 9, all liquid crystal displays inherently have a second substrate opposing the first substrate, with liquid crystal between the two substrates.

As to claims 25 and 26, each limitation recites forming a specific structural element shown in figure 1 of Izumi. The claims are therefore anticipated.

Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

3. Claims 5, 17 and 23-25 rejected under 35 U.S.C. 103(a) as being unpatentable over Kashiwazaki et al. (U.S. 5,922,401).

As to claims 5 and 17, Kashiwazaki et al. does not disclose forming the color filter over an insulating layer. However, it was well known and obvious to do this in

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order to prevent ions from migrating from the substrate into the liquid crystal. Therefore,

it would have been obvious to one of ordinary skill in the art at the time of invention to

form the color filter over an insulating layer in order to prevent ion migration.

As to claims 23 and 24, Kashiwazaki et al. does not disclose patterning the light-

shielding layer, and then using it as a mask to form the source and drain electrodes.

However, this was well known and obvious as a way of simplifying the manufacturing

process. Therefore, it would have been obvious to one of ordinary skill in the art at the

time of invention to form the source and drain electrodes using the light-shielding layer

as a mask in order to simply the manufacturing process.

Conclusion

Any inquiry concerning this communication or earlier communications from the

examiner should be directed to David Chung whose telephone number is (703) 306-

0155. The examiner can normally be reached on Monday-Friday from 8:30 am to 5:00

pm.

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